

Notice of Allowability	Application No.	Applicant(s)
	10/632,944	AHMED ET AL.
	Examiner	Art Unit
	Fetsum Abraham	2826

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

1. This communication is responsive to the amt after RCE and the examiner's amt aproved applicant's representative..
2. The allowed claim(s) is/are 1-13 and 27-38.
3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 - a) All
 - b) Some*
 - c) None
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

* Certified copies not received: _____.

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.
THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.

4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.
 - (a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached
 - 1) hereto or 2) to Paper No./Mail Date _____.
 - (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date _____.

Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

Attachment(s)

1. Notice of References Cited (PTO-892)
2. Notice of Draftsperson's Patent Drawing Review (PTO-948)
3. Information Disclosure Statements (PTO-1449 or PTO/SB/08),
Paper No./Mail Date _____
4. Examiner's Comment Regarding Requirement for Deposit
of Biological Material
5. Notice of Informal Patent Application (PTO-152)
6. Interview Summary (PTO-413),
Paper No./Mail Date _____.
7. Examiner's Amendment/Comment
8. Examiner's Statement of Reasons for Allowance
9. Other _____.

EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Ms. Mimi Diemmy Dao on 9/23/05.

The application has been amended as follows:

The expression "external boundary of the" is added before the "self-aligned recess" in line 6 of claim 1, line 6 of claim 3, line 13 of claim 4, line 6 of claim 5, line 6 of claim 6, line 7 of claim 27.

Statement of reasons for allowance

Claims 1-12, 27-38 have been allowed.

Similar to the claimed bipolar structures with self-aligned recess sharing a boundary with an emitter have been formed in the past. Such an example is EP 0 354 153 A2 submitted by applicant. However, the bipolar structure is formed between insulation layers (36,38) formed on substrate (32) and the structure has a single emitter layer. The claimed process of making a bipolar transistor, however, is formed between insulation layers formed in a substrate (12) and includes an emitter stack, a stack understood to be composed of multiple layers. Although not in the claim language, the fact that the transistor is formed inside a substrate gives it the advantage of having a collector region with the same conductivity type to the substrate (see page 7, 5-12 of the

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specification) as compared to the different conductivity type materials used for the substrate and the collector of the prior art. Besides other differences between the two products, the above-mentioned structural difference, which necessitates a difference in their processing steps, renders the claimed processing method of a bipolar transistor unique and novel.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fetsum Abraham whose telephone number is: 571-272-1911. The examiner can normally be reached on 8:00 - 18:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J Flynn can be reached on 571-272-1915.



Fetsum Abraham
09/25/05

A handwritten signature in black ink, appearing to read "Fetsum Abraham". Below the signature, the date "09/25/05" is written in a smaller, cursive hand.